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GAS-PHASE POLLUTANT DECOMPOSITION WITH NON-THERMAL PLASMAS: SIMPLE REMOVAL **EQUATIONS AND FIGURES-OF-MERIT**

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Gas-Phase Pollutant Decomposition with Non-Thermal Plasmas: Simple Removal Equations and Figures-of-Merit

5th International Conference on Advanced Oxidation Technologies for Water & Air Remediation (AOTs-5)

Louis A. Rosocha Los Alamos National Laboratory



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GAS-PHASE POLLUTANT DECOMPOSITION WITH NON-THERMAL PLASMAS (NTPS): SIMPLE REMOVAL EQUATIONS AND FIGURES-OF-MERIT

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Abstract

plasmas are good sources of highly reactive oxidative and reductive species (free radicals and others), e.g., O(³P), OH, N, H, NH, CH, O₃, O₂ (¹∆), electron temperature). In NTPs, the electrons are highly energetic (hot) and the ions and background gas species are at near-ambient temperature Non-thermal plasmas (NTPs) are a type of advanced oxidation and reduction technology for treating gas-phase chemical pollutants. Such and plasma electrons. Because radical-attack reaction rate constants are very large for many chemical species, entrained pollutants are readily decomposed by NTPs. Via these reactive species, one can direct electrical energy into favorable gas chemistry through energetic electrons, rather than using the energy to heat the gas. NTPs are commonly created by an electrical discharge in a gas or the injection of an energetic electron beam into a gas. Both methods create secondary plasma electrons, with a distribution of electron energies defined by an average electron energy (or (cold). For this reason, these plasmas are sometimes called cold plasmas.

Applications of the technology include flue-gas treatment (SO_x and NO_x), environmental remediation of volatile organic compounds (VOCs) in soil or groundwater, or the abatement of other regulated industrial air emissions.

In this talk, we will describe a simple free-radical-based, reaction-kinetics model that predicts the form of the pollutant-removal plots (degree non-chlorinated VOCs), using removal equations derived from the model. Here, we consider the NTP reactor to be a 'black box' which reduces the of removal vs. specific plasma energy) for various air pollutants and/or hazardous chemicals (e.g., the flue gases SO_x and NO_x and chlorinated and concentration of entrained pollutants in a gas-phase stream from an initial value [X]₀ to a value [X] under the influence of a reactor specific energy (active-plasma energy per unit volume) E.

In general, a pollutant-removal equation is exponential in character, depending only on the applied specific energy Ε and a parameter β. The β-value characterizes the particular pollutant of interest and, for general cases, depends on the active decomposing-species formation efficiency G (number of active molecules produced per 100 eV of plasma-deposited electrical energy), the initial pollutant concentration, and the chemical kinetics of radical-pollutant attack and radical scavenging.

radical-radical scavenging is dominant. In the first case, the removal plot is relatively insensitive to [X]0; in the second case, it significantly depends on [X]₀; and in the third case, the plot is insensitive to [X]₀ but has an explicit dependence on the gas residence time τ, in the NTP reactor – in We will examine three special cases: 1) radical scavenging dominates radical attack, 2) radical attack dominates radical scavenging, and 3) contrast to the other two cases.

From the removal equations, one can derive figures-of-merit for both the instantaneous (γ_i) and average (γ) removal energy costs (energy efficiency) for pollutant removal. We will present example figure-of-merit calculations for representative pollutants and carrier gases to illustrate the dependence on initial concentration [X]₀, the degree of pollutant removal [X]/[X]₀, and the G-value.

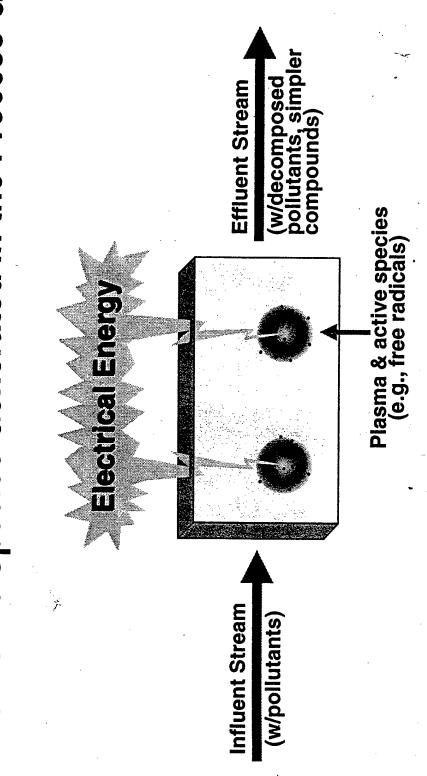
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Outline of talk

- Simple "black-box" model of an NTP reactor
- Active-species production functional relationships
 - Decomposition chemistry overview
- Simple kinetics model and generalized pollutant-removal equations.
- Figures-of-merit & costs for decomposition of example pollutants
- Summary

Via Active Species Generated in the Process Gas Non-thermal Plasmas Decompose Pollutants



depends on the gaseous electronics. Radical generation is mainly initiated by energetic-The radical production efficiency (G-value) electron collisions.

$$G = f\left(\frac{k_{rad}}{\frac{E}{V_d E}}\right)$$

- E/N is the reduced field,
- V_d is the electron drift velocity, which depends on E/N,
- k_{rad} is the rate constant for radical formation (e.g., a dissociation rate constant, which depends on E/N), and/or other rate constants.

Gas-phase plasma chemical decomposition is driven by electron impact and radical attack.

(1) $e + X \rightarrow products$

- (2) O, OH, N, etc. + X → products
- The first reaction is dominant at large pollutant mole fractions.
- The second dominates at smaller mole fractions.

(More energy is directly absorbed by pollutant at high mole fraction, hence electron channel dominates.)

Plasma chemical decomposition of VOCs produces a variety of terminal products.

- e, O, OH, N, etc. + X → products
- Manageable products: CO₂, CO, Cl₂, HCl, COCl₂
- Undesirable products: Other halocarbons, hazardous byproducts (e.g., DCAC - CHCl₂COCI); polymers
- Secondary treatment:

 CO₂ + NaOH → NaHCO₃

 CO + catalyst→ CO₂

 Cl₂ + NaHCO₃→ NaCl + HCl + ...

 HCl + NaOH → NaCl + H₂O

 COCl₂ + H₂O→ 2HCl + CO₂

Major de-NO_x Reactions in Moist Gas Mixtures w/o HCs

$$\begin{array}{c} 0 + NO + M \ \, \rightarrow \ \, NO_2 + M \ \, \rightarrow \ \, NO_2 + NO_2 \\ 0 + NO_2 \ \, \rightarrow \ \, NO + O_2 \\ 0 + N_2 \ \, \rightarrow \ \, NO + N \\ 0 + O_2 + M \ \, \rightarrow \ \, O_3 + M \\ 0_3 + NO_2 \ \, \rightarrow \ \, NO_2 + O_2 \\ 0_3 + NO_2 \ \, \rightarrow \ \, NO_3 + O_2 \\ 0_3 + NO_2 \ \, \rightarrow \ \, NO_3 + O_2 \\ 0_3 + NO_2 \ \, \rightarrow \ \, NO_3 + O_2 \\ 0_3 + NO_2 \ \, \rightarrow \ \, NO_3 + O_2 \\ 0_1 + NO_2 \ \, \rightarrow \ \, NO_3 + O_3 \\ 0_1 + NO_2 \ \, \rightarrow \ \, NO_3 + O_4 \\ 0_1 + NO_2 \ \, \rightarrow \ \, NO_3 + O_4 \\ 0_1 + NO_2 \ \, \rightarrow \ \, NO_3 + O_4 \\ 0_1 + NO_2 \ \, \rightarrow \ \, NO_3 + O_4 \\ 0_1 + NO_2 \ \, \rightarrow \ \, NO_3 + O_4 \\ 0_1 + NO_2 \ \, \rightarrow \ \, NO_3 + O_4 \\ 0_1 + NO_2 \ \, \rightarrow \ \, NO_3 + O_4 \\ 0_2 + NO_3 \ \, \rightarrow \ \, NO_4 \\ 0_3 + NO_2 \ \, \rightarrow \ \, NO_4 \\ 0_3 + NO_2 \ \, \rightarrow \ \, NO_4 \\ 0_4 + NO_2 \ \, \rightarrow \ \, NO_4 \\ 0_5 + NO_3 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_2 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_3 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_3 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_2 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_3 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_3 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_3 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_4 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_4 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow \ \, NO_5 \ \, NO_5 \\ 0_7 + NO_5 \ \, \rightarrow$$

$$N(^{2}D) + H_{2}O \rightarrow NH + OH$$

 $NH + NO \rightarrow N_{2} + OH$
 $NH + O_{2} \rightarrow NO + OH$
 $NO + NO_{3} \rightarrow 2NO_{2}$
 $NO + OH + M \rightarrow HNO_{2} + M$
 $OH + HNO_{2} \rightarrow NO_{2} + H_{2}O$
 $OH + HNO_{2} \rightarrow NO_{2} + H_{2}O$
 $OH + NO_{2} \rightarrow M \rightarrow HNO_{3} + M$
 $N + NO_{2} \rightarrow NO + N_{2}$
 $N + NO_{2} \rightarrow NO + N_{2}$
 $O(^{1}D) + NO_{2} \rightarrow NO + O_{2}$
 $O(^{1}D) + O_{2} \rightarrow NO + O_{2}$
 $O(^{1}D) + O_{2} \rightarrow NO + O_{2}$
 $O(^{1}D) + O_{2} \rightarrow NO + O_{2}$

Primary Acid-Formation Pathways:

$$NO + OH + M \rightarrow HNO_2 + M$$

 $OH + NO_2 + M \rightarrow HNO_3 + M$

The presence of SO₂ recycles OH radicals & reduces effective de-NO_x energy cost

OH + SO₂ + M
$$\rightarrow$$
 HSO₃ + M
HSO₃ + O₂ \rightarrow HO₂ + SO₃
HO₂ + NO \rightarrow NO₂ + OH

The OH radical then goes on to be used again in de-NO_x

OH + NO + M
$$\rightarrow$$
 HNO₂ + M
OH + HNO₂ \rightarrow NO₂ + H₂O
OH + NO₂ + M \rightarrow HNO₃ + M

Acid is also formed by the reaction

$$HSO_3 + H_2O \rightarrow H_2SO_4$$

With ammonia (NH₃) addition, useful particulates (fertilizer) can be formed from NO_x

$$e + NH_3 \rightarrow NH_2 + H + e$$

 $e + NH_2 \rightarrow NH + H + e$
 $NH + H \rightarrow N + H_2$
 $NH_2 + NO \rightarrow N_2 + H_2O$
 $NH + NO \rightarrow N_2 + OH$
 $N + NO \rightarrow N_2 + OH$
 $N + NO \rightarrow N_2 + OH$

OH + NH₃ \rightarrow NH₂ + H₂O OH + NO + M \rightarrow HNO₂ + M OH + HNO₂ \rightarrow NO₂ + H₂O OH + NO₂ + M \rightarrow HNO₃ + M NH₃ + HNO₃ \rightarrow NH₄NO₃ (Ammonium Nitrate fertilizer)

Simple, first-order kinetics model gives exponential pollutant-removal function.

Chemical Reactions

Rate Equations

$$\frac{d[R\cdot]}{dt} = \frac{d[R\cdot]}{d\overline{E}} \cdot \frac{d\overline{E}}{dt} = G\overline{P}$$

$$R^{\bullet} + X \rightarrow Products$$

$$\frac{d[X]}{dt} = -k[R \cdot][X]$$

(7)

$$R^{\bullet} + S_i \rightarrow Products$$

$$\frac{d[\mathbb{R}\cdot]}{dt} = -k_{S_i}[\mathbb{R}\cdot][S_i]$$

<u>ල</u>

Assume steady state:
$$\frac{d[\mathbb{R}\cdot]}{dt}(net) = G\overline{P} - k[\mathbb{R}\cdot][X] - \sum_{k_{S_i}} [\mathbb{R}\cdot][S_i] = 0$$

Solve for [R]ss and insert into (2) to obtain generalized removal equation.

A generalized removal equation depends on plasma chemistry (radical yields), reaction chemistry, and applied plasma specific energy.

Generalized olifferential equation: |For low degree of removal (i.e.,

$$\frac{k[X] + \sum_{i} k_{S_i} [S_i]}{k[X]} d[X] = -G d\overline{\mathbf{E}}$$

Integration with limits [X], → [X] and 0 → E gives:

$$\frac{[X]}{[X]_0} + \frac{\sum_{i} k_{S_i} [S_i]}{k [X]_0} \ln \frac{[X]}{[X]_0} - 1 = -\frac{G\overline{\mathsf{E}}}{[X]_0}$$

For low degree of removal (i.e., |X|/|X|₀ ~ 1 + ln { |X|/|X|₀}), an analytical solution is obtained:

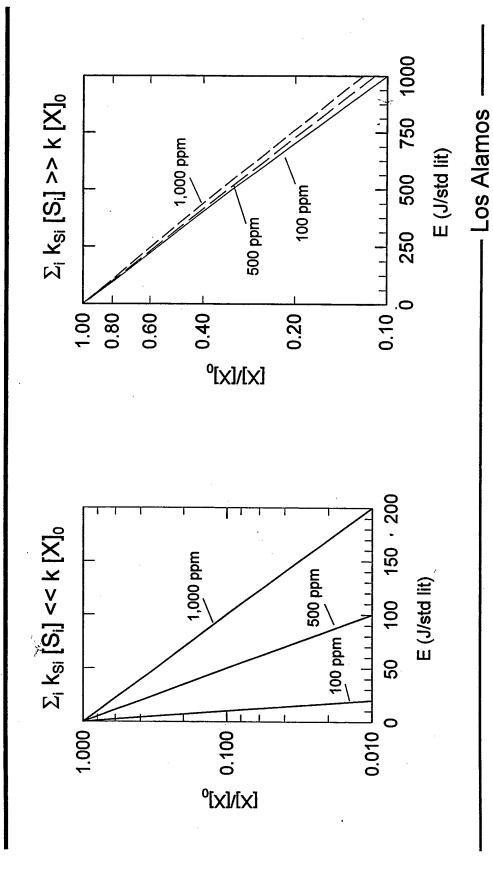
$$[X]/[X]_0 = \exp(-\overline{\mathbf{E}}/\beta)$$

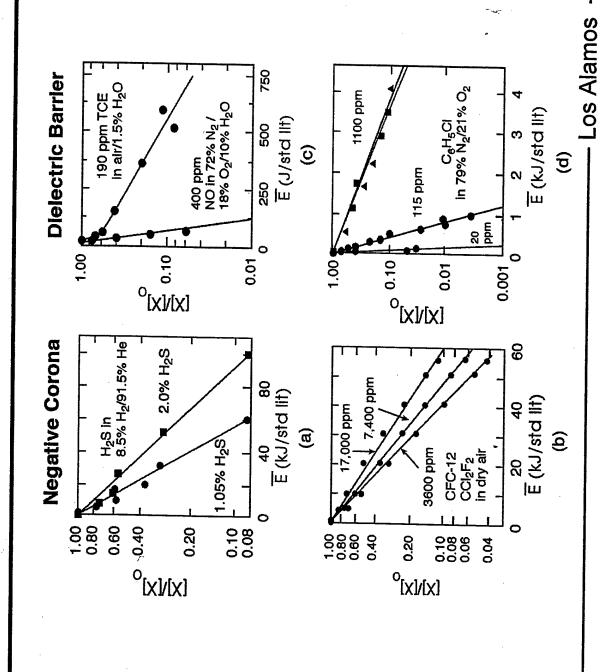
where

$$\beta = \frac{1}{G} \left([X]_0 + \frac{\sum_i k_{S_i} [S_i]}{k} \right)$$

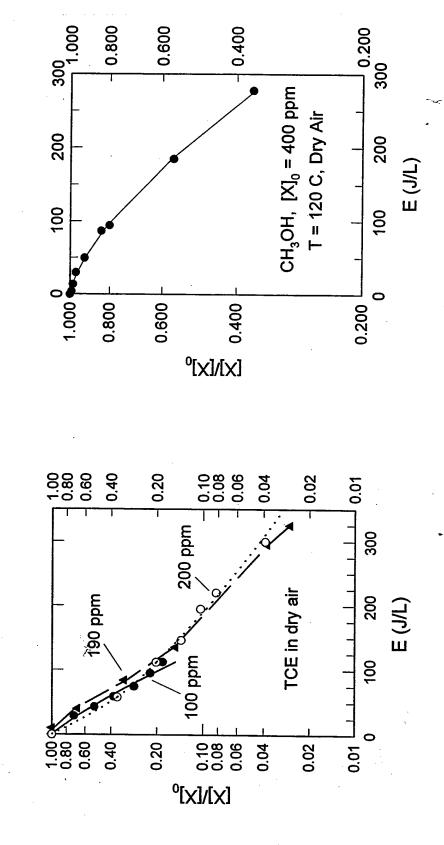
When k |X| << Σ_i k_{Si} [S_i], the β-value and, hence the degree of removal |X|/ |X|_i shows no dependence on the |Initial concentration |X|_i

removal function (plot of degree of removal vs The simple model predicts the form of the plasma specific energy).





Example removal data for various compounds (cont'd.)



After Falkenstein; Korzekwa & Rosocha

Los Alamos

After Hsiao et al

Example recombination-dominated removal plot (calculated).

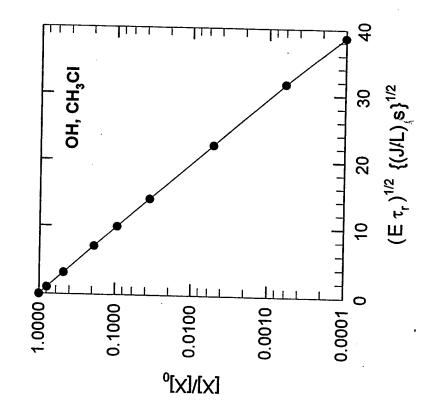
Additional example case (explicit residence-time dependence):

Σ_i k_{Si} [S_i] >> k [X]₀ and dominant scavenging pathway is recombination of the radicals, e.g., [R*] = [S], where S represents the primary scavenger

$$[R^{\bullet}] = (G\overline{P}/k_s)^{1/2}$$

$$\frac{d[X]}{[X]} = -k \left(\frac{G\overline{P}}{ks}\right)^{1/2} dt$$

 $[X]/[X]_0 = \exp\{-k (G\overline{E}/k_s)^{1/2} \tau_r^{1/2}\}$



Ballpark B-value calculation for TCE (C₂HCl₃) in a dry, air-like gas mixture:

Simple Chemical Model

1)
$$e + O_2 \rightarrow O + O + e$$

2) $O + TCE \rightarrow Products$
3) $O + O_2 + M \rightarrow O_3 + M$

G (O) ~ 10 molec/100 eV

$$k_2 = 5.3 \times 10^{-13} \text{ cm}^3/\text{s}$$

 $k_3 = 6.1 \times 10^{-34} \text{ cm}^6/\text{s} \text{ (for M} = O_2)$
 $k'_3 = 5.9 \times 10^{-34} \text{ cm}^6/\text{s} \text{ (for M} = N_2)$

8-Value Estimates

 $\beta = 1/G \{ [X]_0 + 1/k_2 (k_3 [O_2]^2 + k'_3 [O_2] [N_2]) \}$ $\beta \sim 260 \text{ J/liter}$

Without Chain Reactions

Chain length 2: $\beta \sim$ 130 J/liter Chain length 5: $\beta \sim$ 52 J/liter Chain length 10: $\beta \sim$ 26 J/liter

With CI Chain Reactions

Example scaling laws for pollutant removal (no [X]₀ dependence)

(1)
$$[X] = [X]_0 \exp(-\overline{E}/\beta)$$
,

and β is the e-fold energy density. Supplying one β to the reactor reduces the where [X] $_0$ is the initial pollutant concentration, [X] is the resulting concentration, $_{\mathbb E}$ is the applied specific energy (or plasma power divided by gas flow rate, P/Q), concentration by 1/e, 2β by $1/e^2$, and so on.

A useful figure of merit for the decomposition of pollutants is defined by the stream. At any instant, this can be expressed as the following quantity obtained energy delivered to the plasma per hazardous molecule removed from the gas by solving Equation 1 for E and taking the derivative:

(2)
$$\gamma_i = -\frac{d\overline{\mathsf{E}}}{d[X]} = -\frac{d[-\beta \ln(\frac{[X]}{[X]_0})]}{d[X]} = \frac{\beta}{[X]}$$
.

This is the instantaneous energy cost per molecule removed.

Scaling laws for pollutant removal (cont'd)

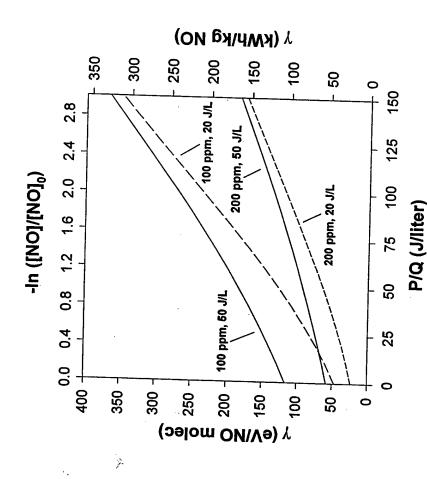
A more practically-useful parameter is the integral, or average, energy cost γ

(3)
$$\gamma = \frac{\bar{E}_{\infty}}{[X]_0 - [X]} = \frac{-\beta \ln(\frac{\lfloor X \rfloor}{[X]_0})}{[X]_0 (1 - \frac{\lfloor X \rfloor}{[X]_0})}$$
 (= $\beta / [X]_0$ (at optimum; i.e., $[X]/[X]_0 \sim 1$).

Here, the energy cost per molecule is expressed in terms of the β -value, the degree of removal, and the initial concentration. When radical-pollutant attack dominates $\beta \approx [X]_0/G$ and the removal cost is then independent of the initial concentration

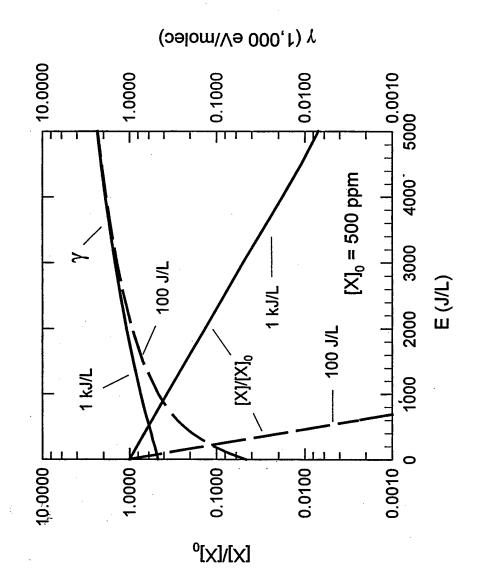
(4)
$$\gamma = \frac{\bar{E}}{[X]_0 - [X]} = \frac{-\ln(\frac{[X]_0}{[X]_0})}{G(1 - \frac{[X]_0}{[X]_0})}$$
 (= 1/G at optimum; i.e., [X]/[X]_0 ~ 1).

Figures-of-merit for pollutant removal



costs decrease as the concentration increases (note 200 ppm case vs 100 ppm case). Energy costs and degree of removal for NO removal in an NO-air mixture with one efold plasma specific energies of 50 J/liter and 20 J/liter. NO is a compound whose etavalue is not very sensitive to the initial concentration; therefore, the removal energy

generalized compound, scavenging dominant Figures-of-merit for pollutant removal:



Summary

- presents phenomenological descriptions of reactor performance and, in most cases, does not provide a consistent way to compare and/or Most technical literature on treating air emissions with NTPs mainly predict the scaling and optimization properties of different NTP systems.
- unit volume deposited in the reactor active volume) required to remove A simple way of comparing different types of NTP reactors, is based mixture and the associated yield (electrical energy cost per mass of on the concept of: the plasma specific energy (electrical energy per a particular pollutant to a prescribed level in a defined exhaust-gas pollutant removed.
- We have described simple models for pollutant-removal and figures-ofmerit for energy-removal costs in generalized NTP reactors.

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Non-thermal plasmas (NTPs) are a type of advanced oxidation and reduction technology for treating gas-phase chemical pollutants. Such plasmas are good sources of highly reactive oxidative and reductive species (free radicals and others), e.g., O(3P), OH, N, H, NH, CH, O₃, O₂ (¹\D), and plasma electrons. Because radical-attack reaction rate constants are very large for many chemical species, entrained pollutants are readily decomposed by NTPs. Via these reactive species, one can direct electrical energy into favorable gas chemistry through energetic electrons, rather than using the energy to heat the gas. NTPs are commonly created by an electrical discharge in a gas or the injection of an energetic electron beam into a gas. Both methods create secondary plasma electrons, with a distribution of electron energies defined by an average electron energy (or electron temperature). In NTPs, the electrons are highly energetic (hot) and the ions and background gas species are at near-ambient temperature (cold). For this reason, these plasmas are sometimes called cold plasmas.

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